

Chlorophyll-sensitized microporous cuprous iodide photocathode

K. Tennakone, A.R. Kumarasinghe, P.M. Sirimanne, G.R.R.A. Kumara

Institute of Fundamental Studies, Hantana Road, Kandy, Sri Lanka

Abstract

A method is given for deposition of a microporous film of cuprous iodide on indium-tin oxide glass substrate. Characteristics of the photocurrent spectra of the chlorophyll-sensitized film under back-wall and front-wall illumination are described.

Keywords: Microporous film; Cuprous iodide; Chlorophyll-sensitized film
